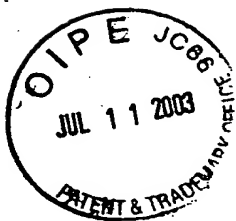


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7/18/03



PATENT

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of:

John E. LANG

Application No: 09/274,194

Filed: October 16, 2001

For: METHOD OF REMOVING PHOTORESIST
MATERIAL WITH DYMETHYL SULFOXIDE

) Docket No: LAM2P266

) Group Art Unit: 1765

) Examiner: C. Brown

) July 7, 2003

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CERTIFICATE OF MAILING

I hereby certify that this correspondence is being deposited with the United States Postal Service as First Class Mail addressed to: Commissioner for Patents, P.O. Box 1450 Alexandria, VA 22313-1450 on July 7, 2003.

Signed:

Courtney F. Yadegar

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

REQUEST FOR RECONSIDERATION

Dear Sir:

In response to the Office Action mailed on March 6, 2003. A response to the Office Action was due on June 6, 2003. Accordingly, Applicant is concurrently submitting a request for a two-month extension of the period for response. Please enter the following amendments and remarks in the above-identified patent application:

Listing of claims beings begins on page 2 of this paper.

Remarks/Arguments begin on page 6 of this paper.

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